

# Systems Engineering and Modeling at Start-Up Company

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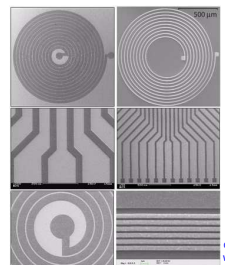
## Abstract

We have been assisting in applying Systems Engineering techniques and methods in a small (tens of persons) start-up company in the semiconductor process and equipment market. We report our observations in this start-up company with an innovative product operating in a dynamic environment. Start-up companies in general explore new applications or new technologies: an environment full of unknowns, uncertainties and other surprises. In the specific case of semiconductor process and equipment the system is highly multi-disciplinary, amongst others: high precision mechanical, control, optics, chemical, signal processing, and power electronics.

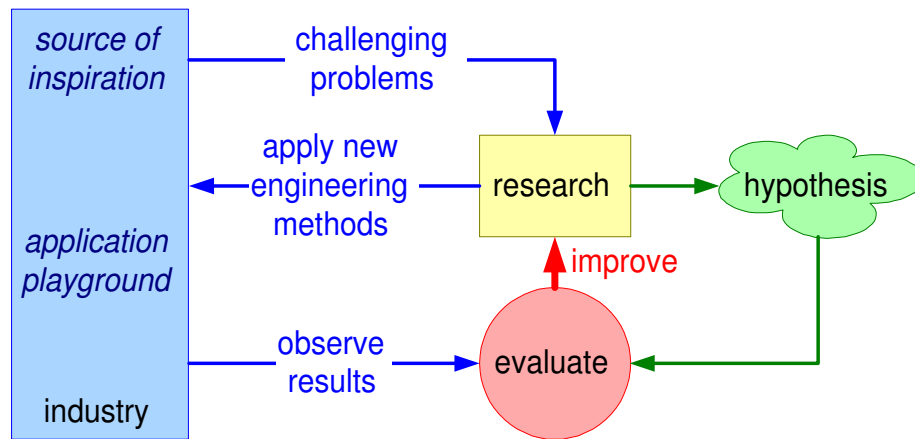
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draft  
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# Figure Of Contents™

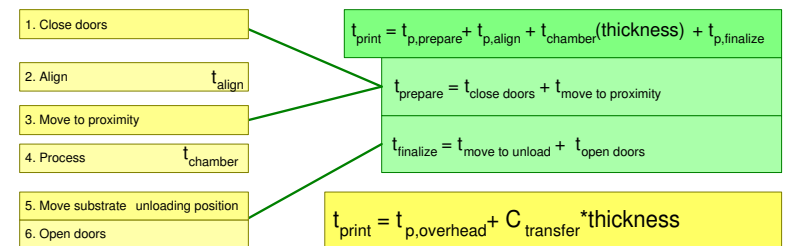
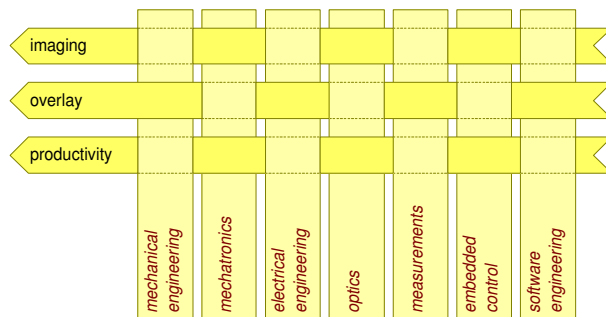


1. SE research

2. Start-up at Kista

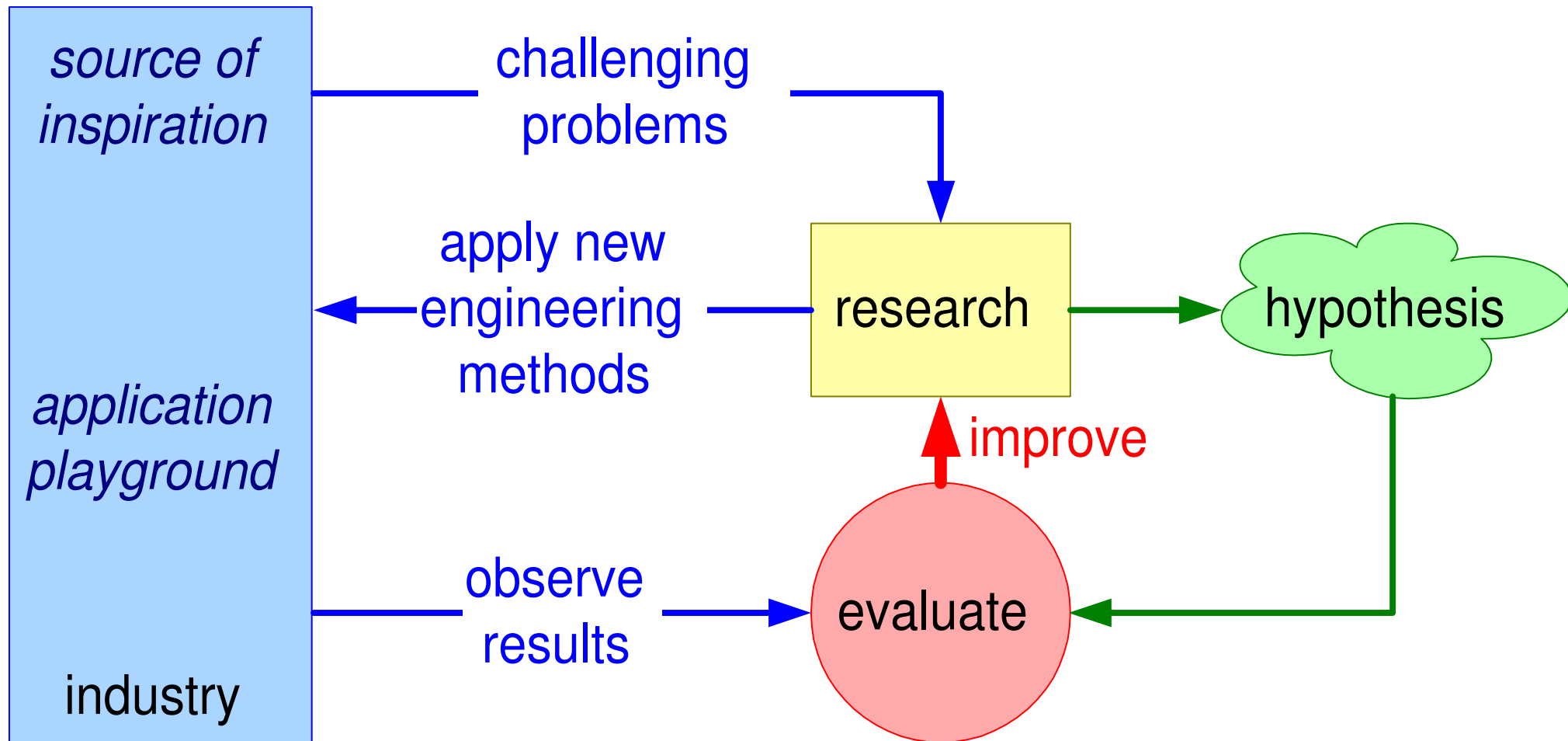
4. Evaluation

3. System Modeling



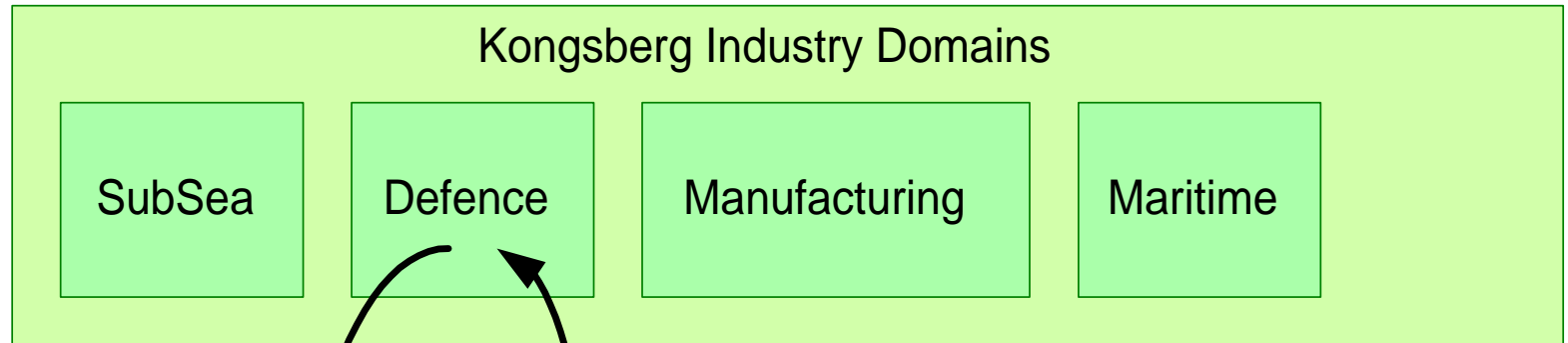
*note: original diagram was annotated with actual performance figures for confidentiality reasons these numbers have been removed*

# Industry as Laboratory



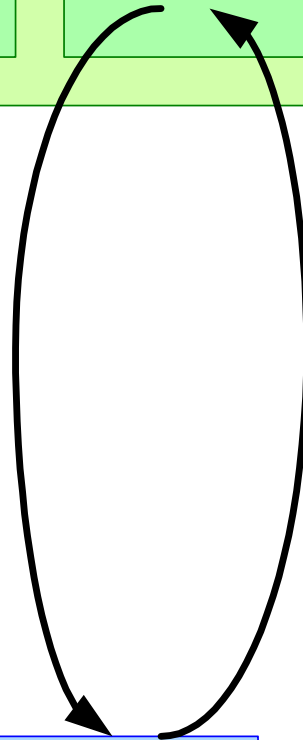
# Industry as Laboratory (2)

intended dissemination and research partners

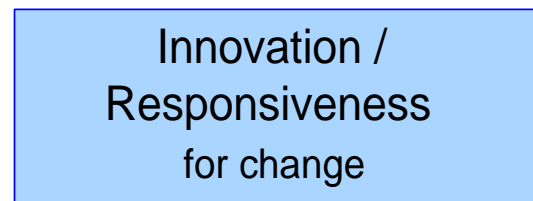
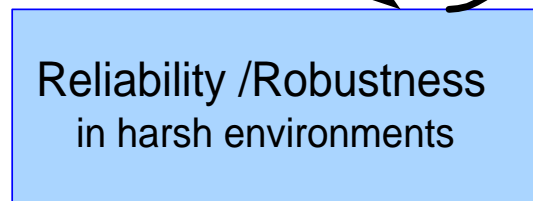


generalization and consolidation to facilitate use in other domains

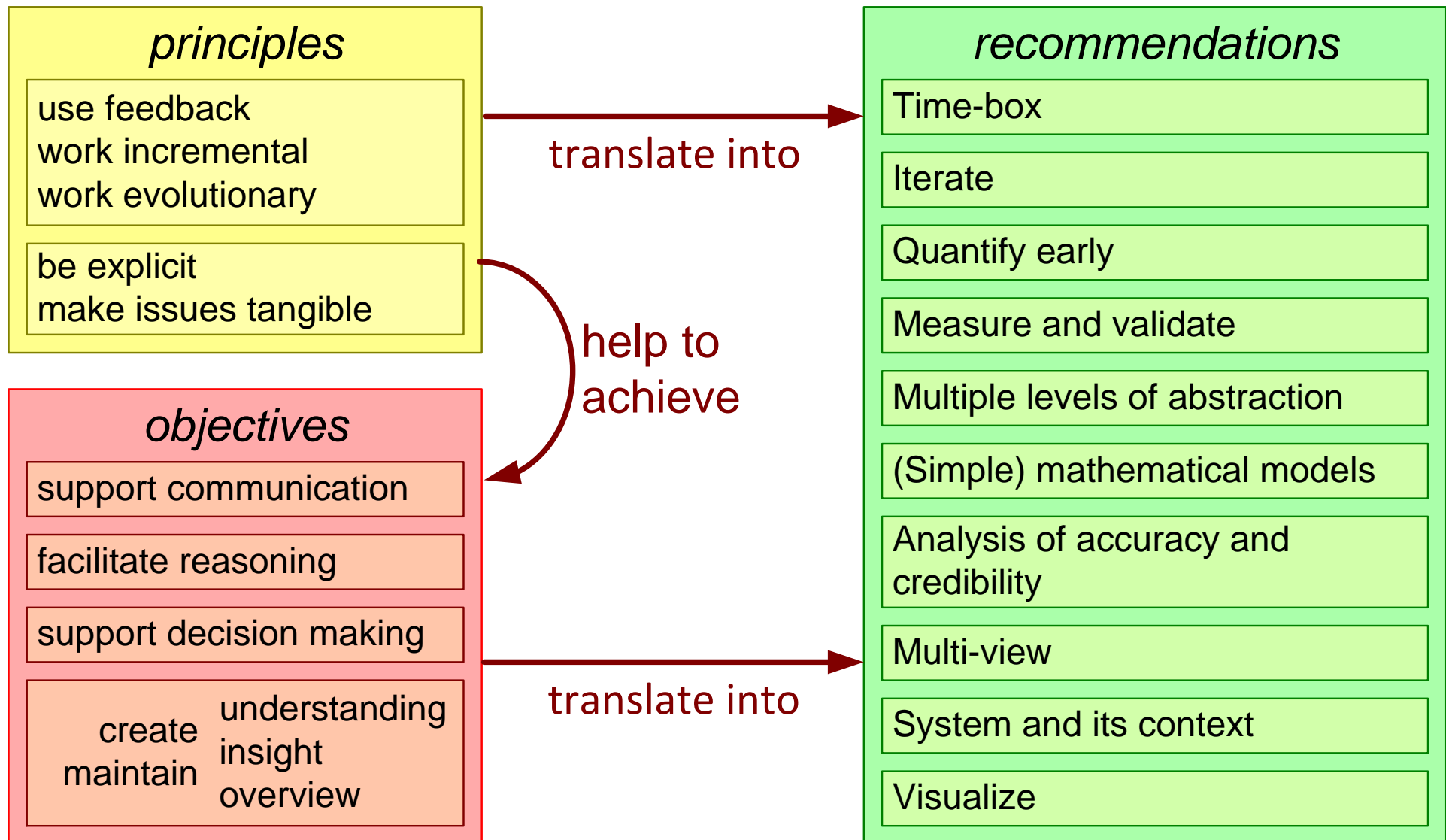
single domain research focus on industrial problem



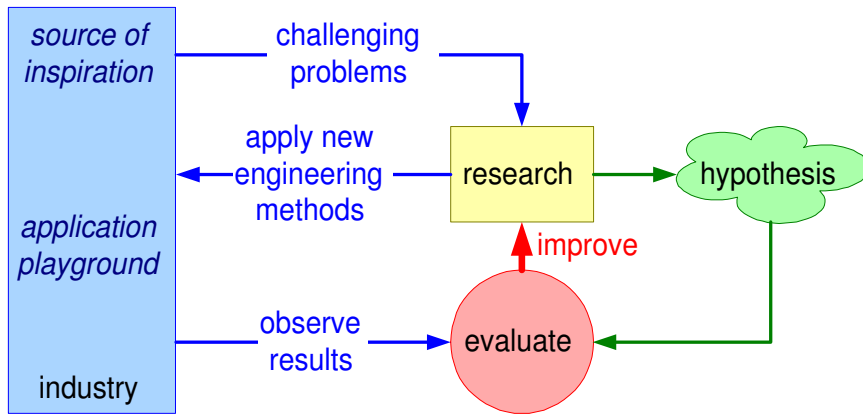
multi-domain research and expertise



# Modeling Recommendations as Applied



# Start-Up Company Replisaurus in Kista (Sweden)

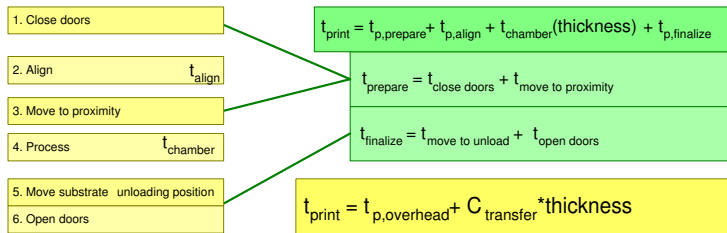
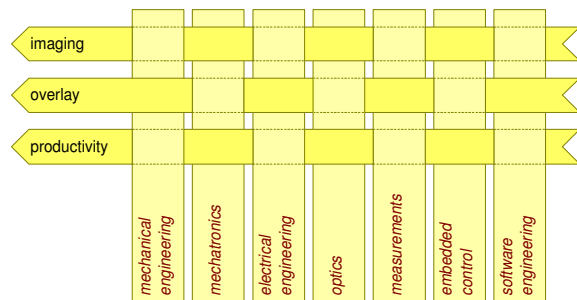


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2. Start-up at Kista

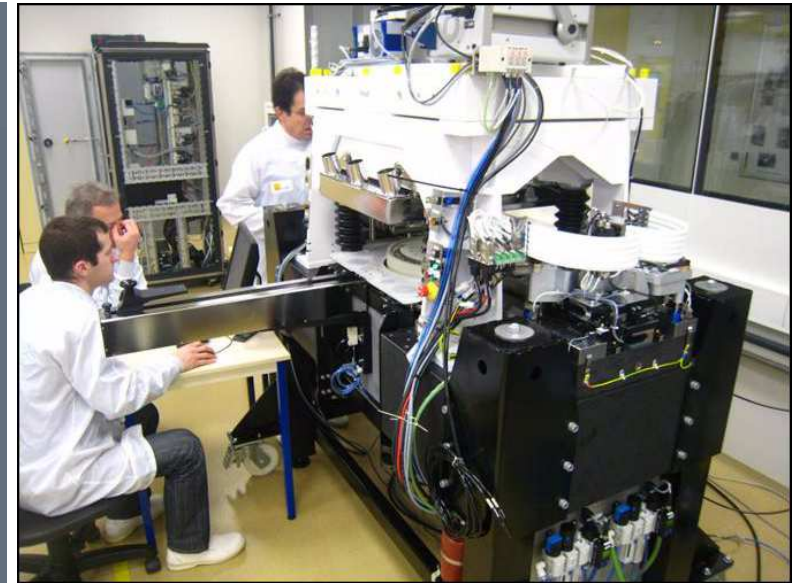
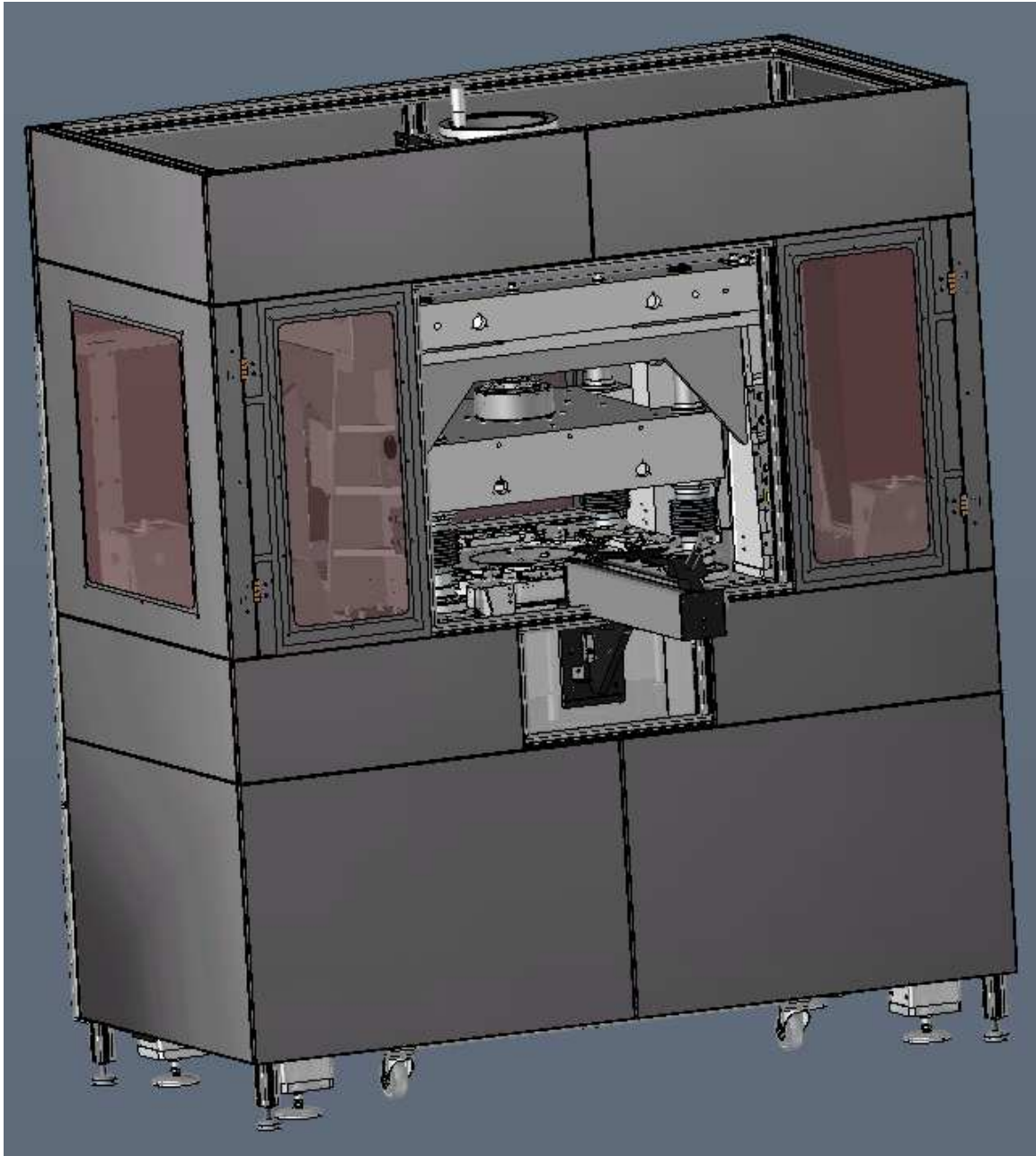
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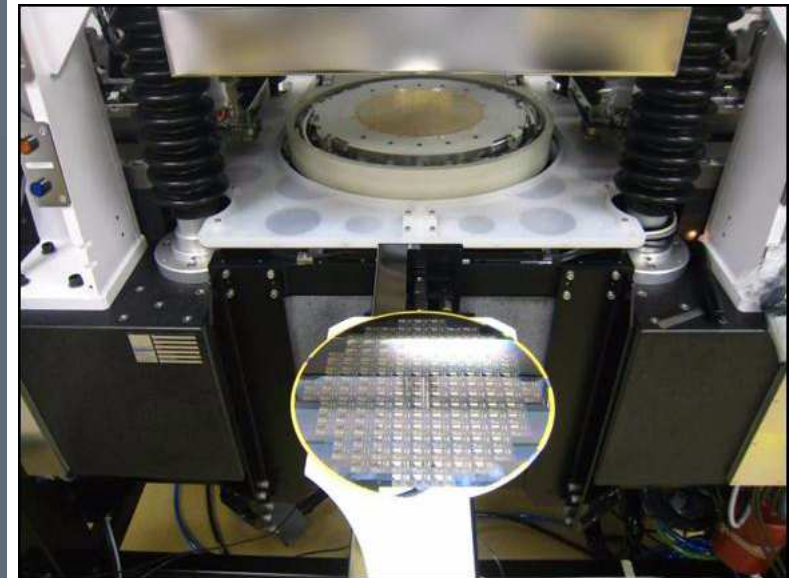


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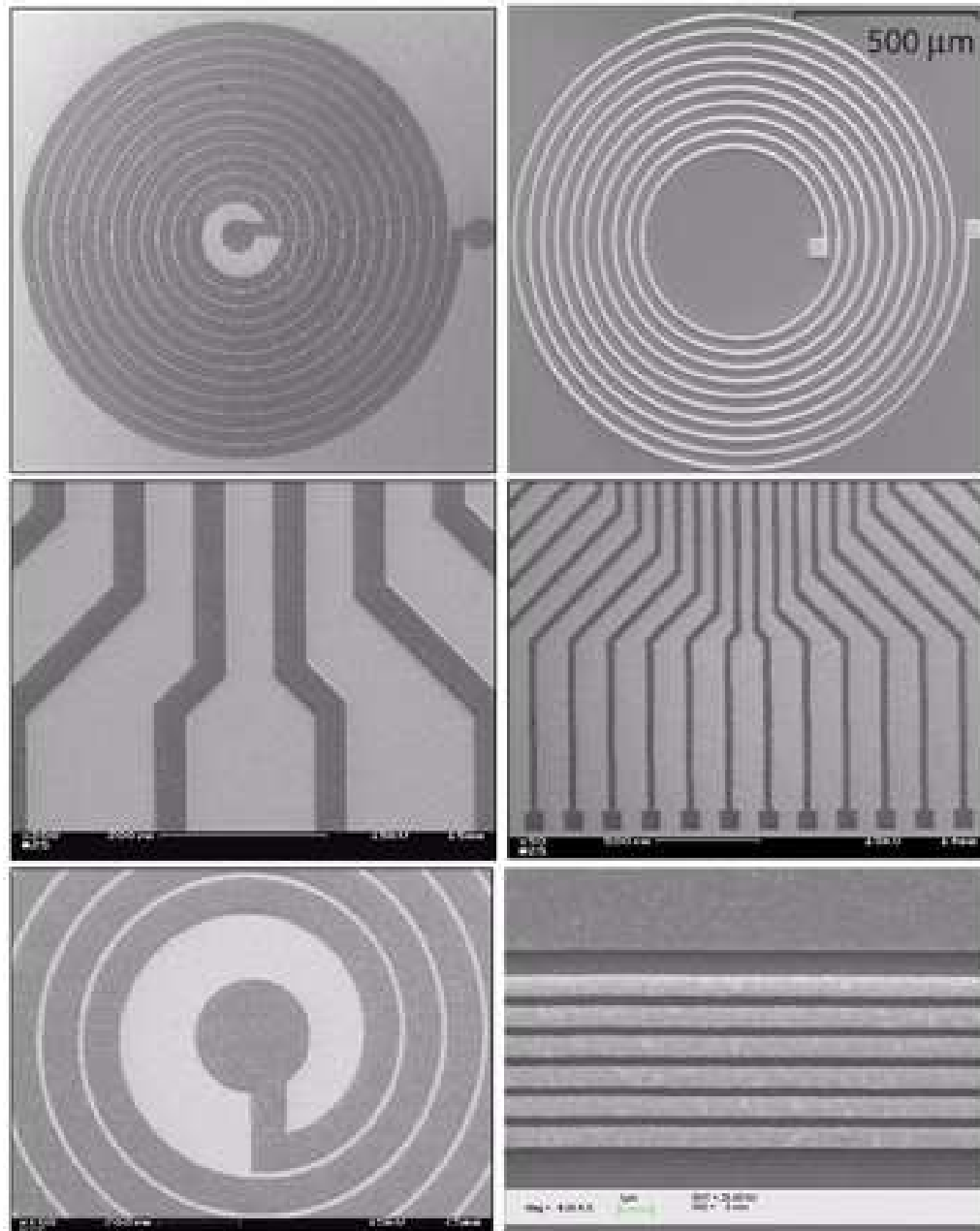
# The Copper Printer



courtesy Replisaurus  
[www.replisaurus.com](http://www.replisaurus.com)



# Example of printed copper structures



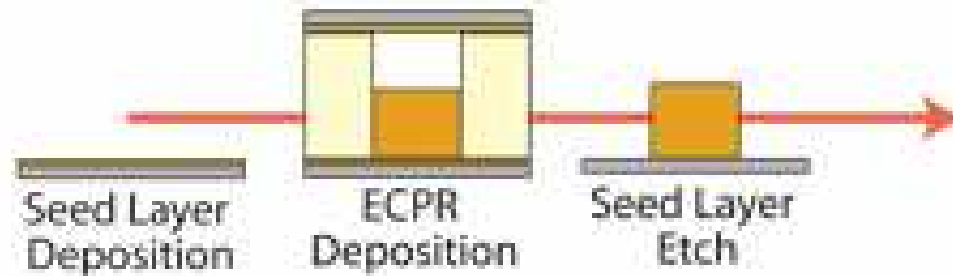
courtesy Replisaurus  
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# ECPR technology replaces 6 process steps by 1 step

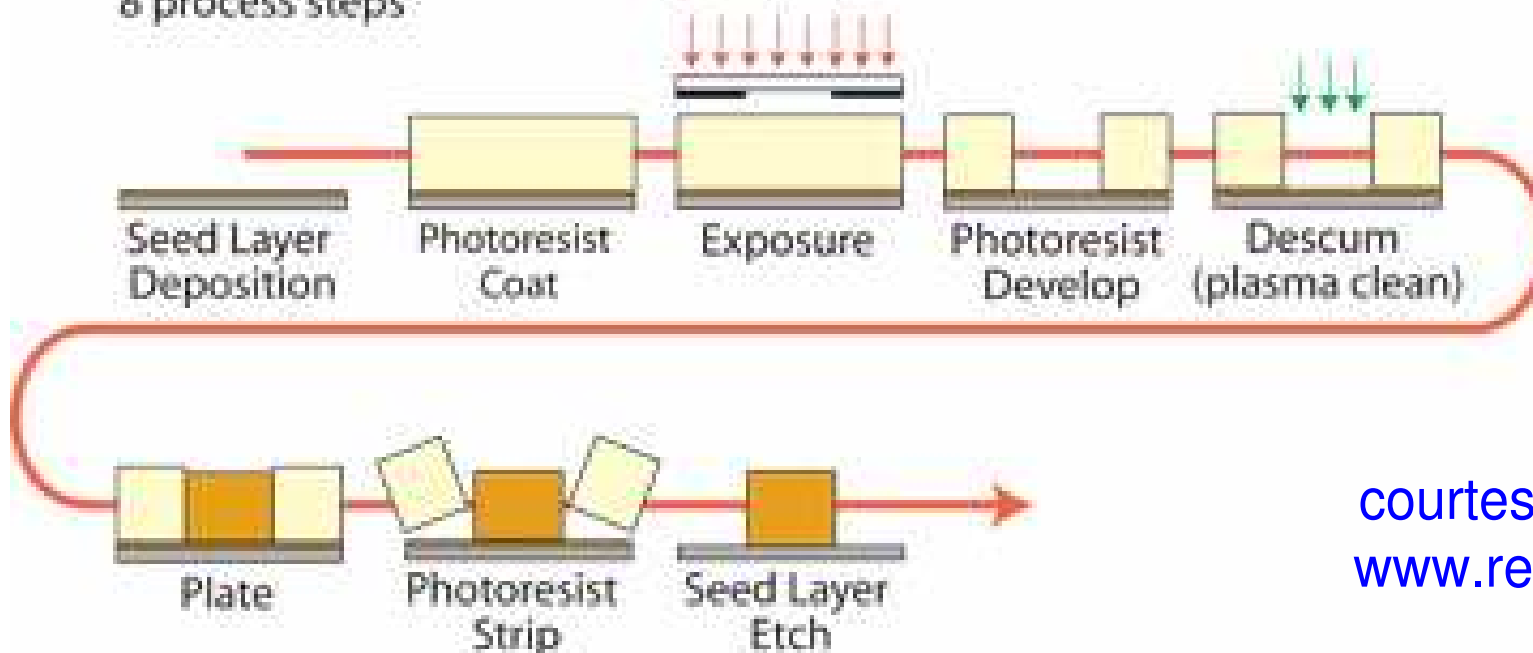
## ECPR - ElectroChemical Pattern Replication

3 process steps



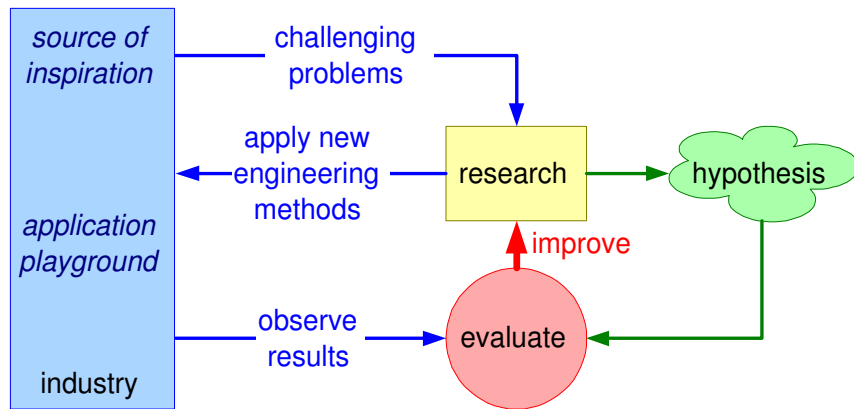
## Conventional lithography based metallization

8 process steps



courtesy Replisaurus  
[www.replisaurus.com](http://www.replisaurus.com)

# System Modeling



1. SE research

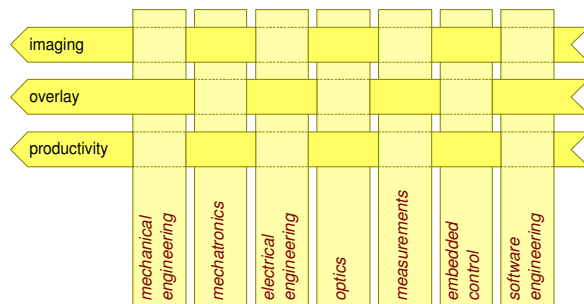
2. Start-up at Kista

4. Evaluation

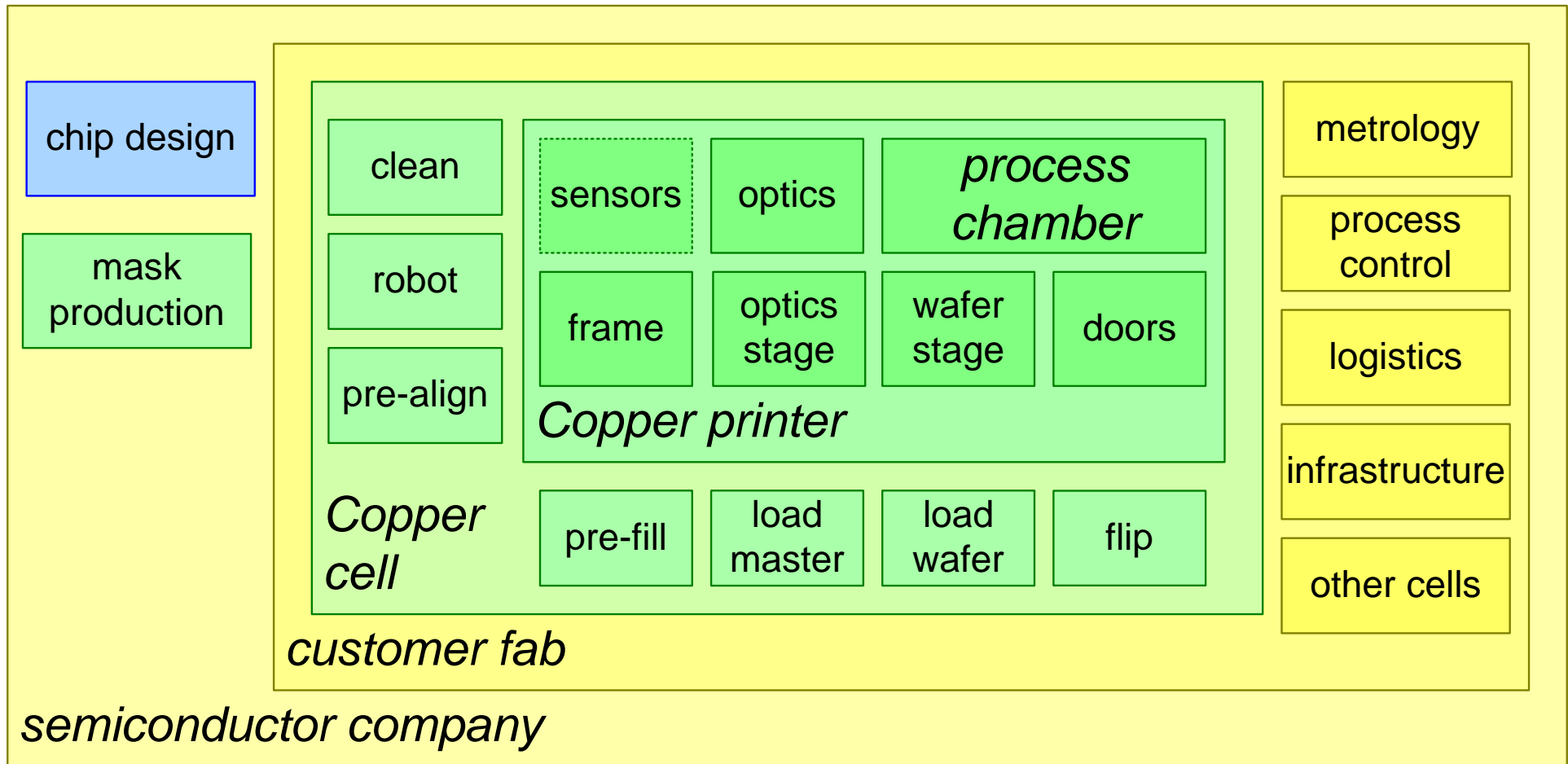
## 3. System Modeling

1. Close doors		$t_{print} = t_{p,prepare} + t_{p,align} + t_{chamber}(thickness) + t_{p,finalize}$
2. Align	$t_{align}$	
3. Move to proximity		
4. Process	$t_{chamber}$	$t_{prepare} = t_{close\ doors} + t_{move\ to\ proximity}$
5. Move substrate unloading position		$t_{finalize} = t_{move\ to\ unload} + t_{open\ doors}$
6. Open doors		
		$t_{print} = t_{p,overhead} + C_{transfer} * thickness$

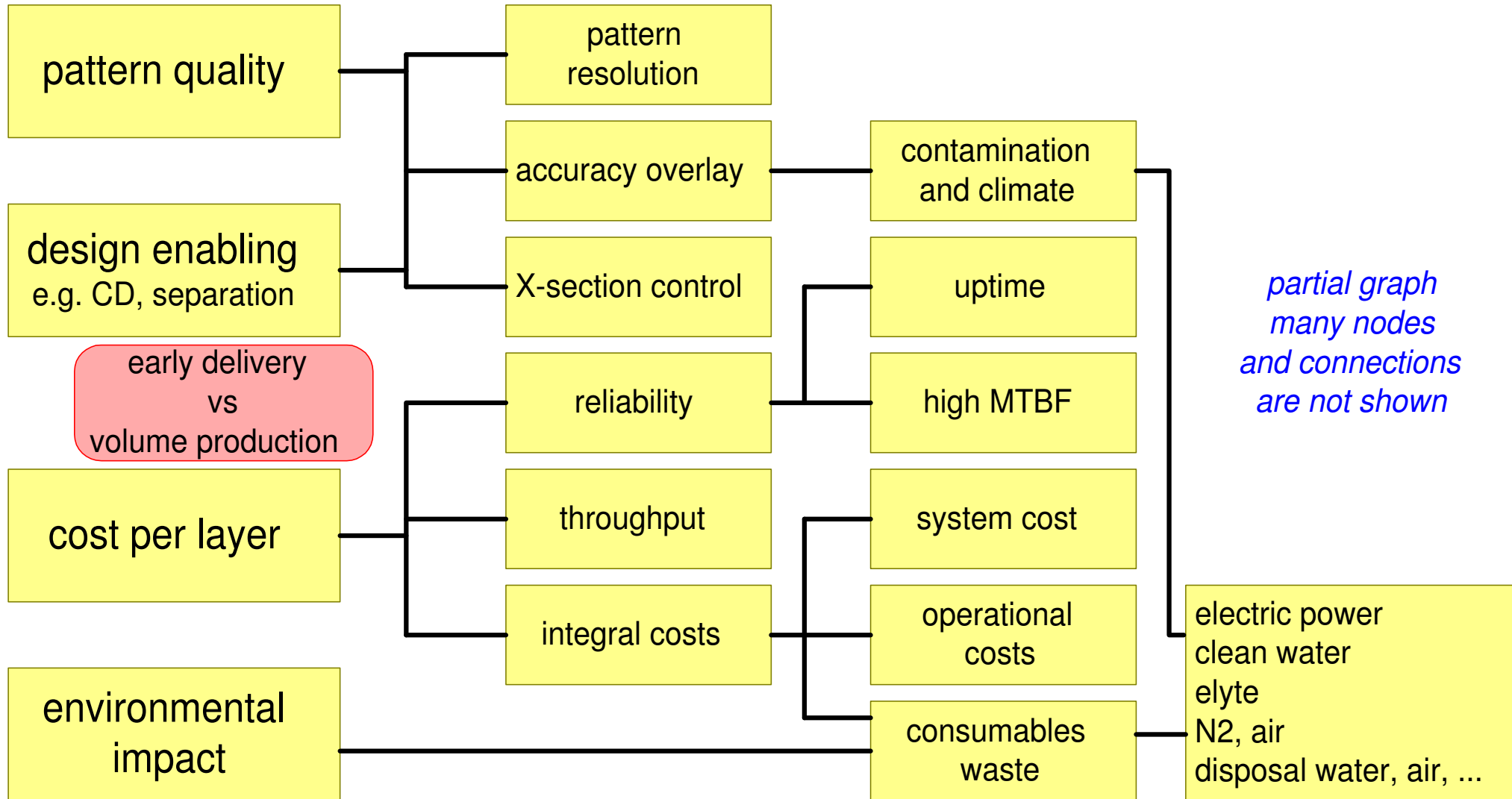
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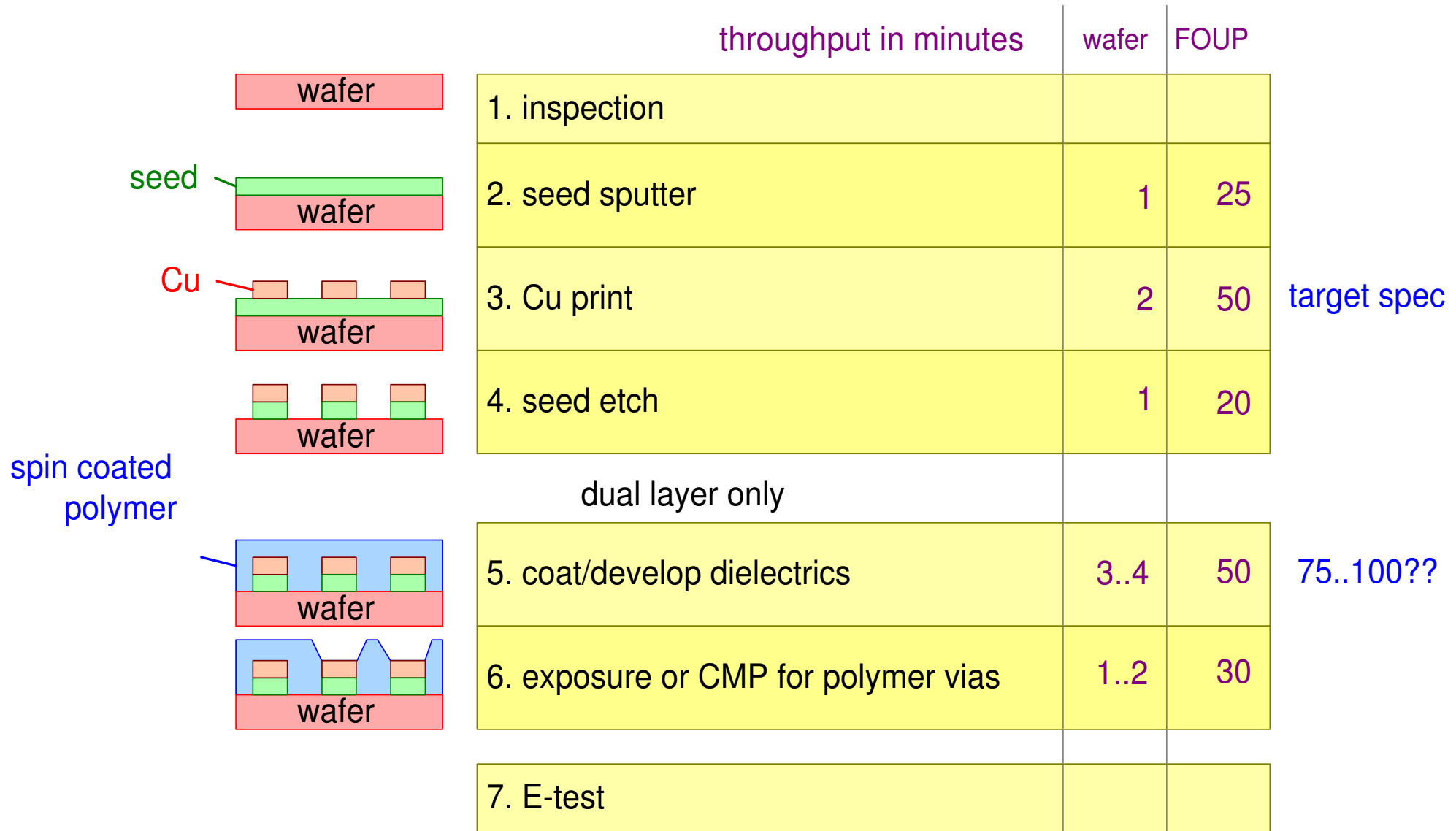
# Overview of the different scopes



# Customer key driver graph



# Process flow at fab level, from inspection until testing



# Work flow in the Copper Printer

0. Loading Master&substrate

1. Close doors

2. Align

3. Move to proximity

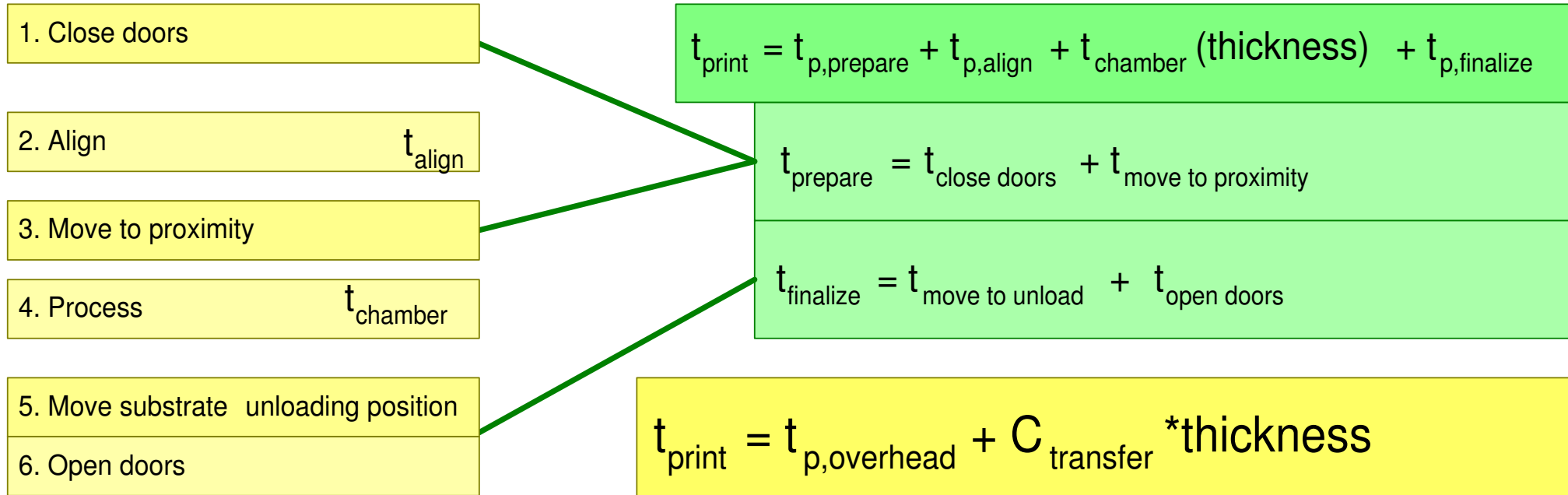
4. Process incl. rinse&dry

5. Move substrate unloading position

6. Open doors

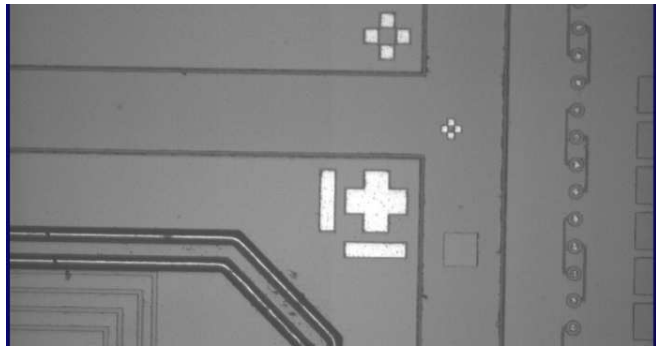
7. Unloading Master&substrate

# Formula of printer throughput time



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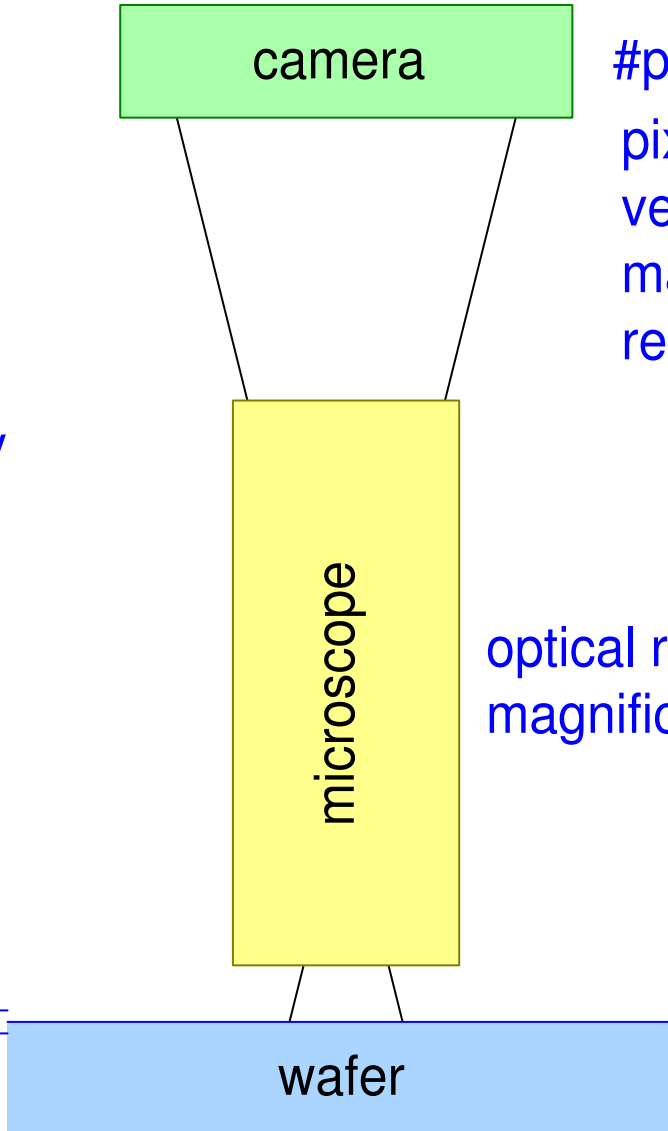
# Optical path to measure marker position



measurement accuracy  
determines  
required resolution



DoF



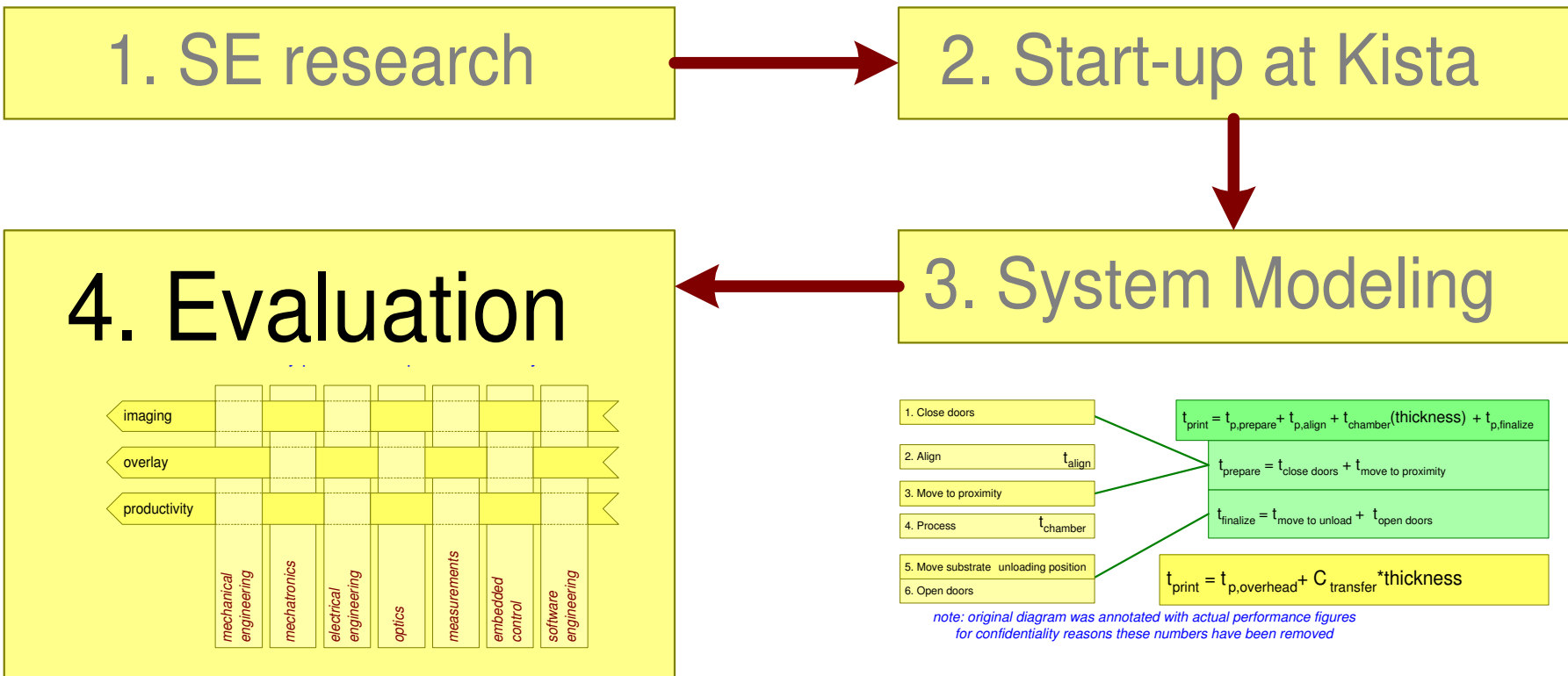
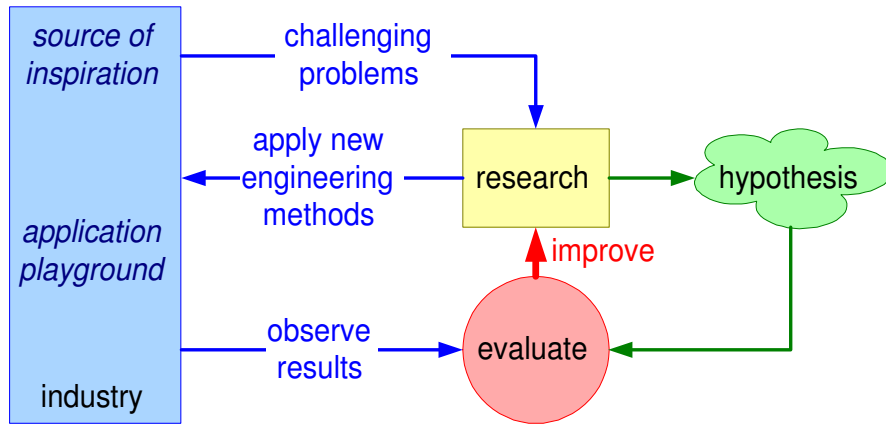
#pixels  $\approx$  5M  
pixel resolution  
versus  
maximum Field of View  
read-out and processing time

optical resolution  
magnification

displacement  
determines  
required Field of View

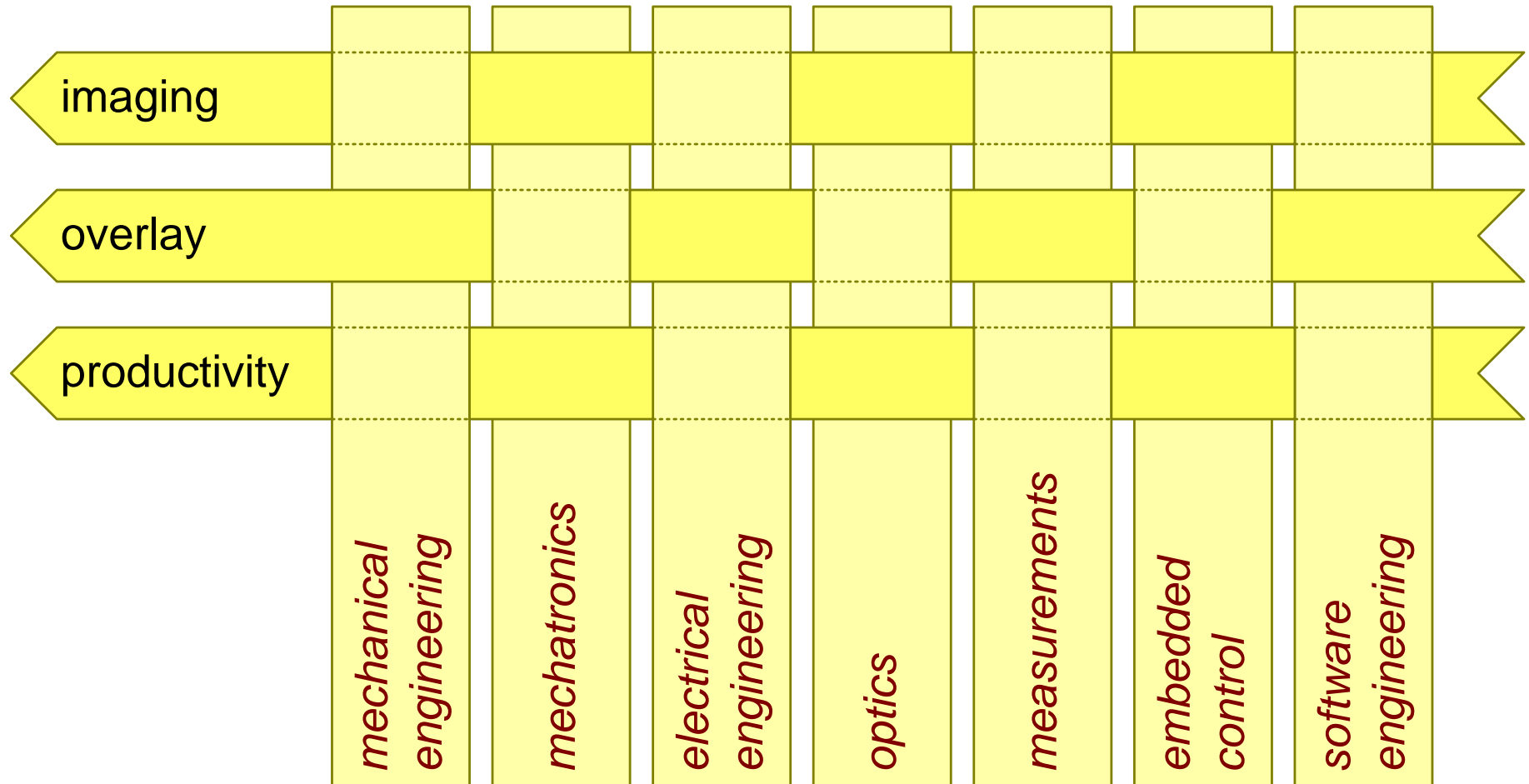


# Evaluation

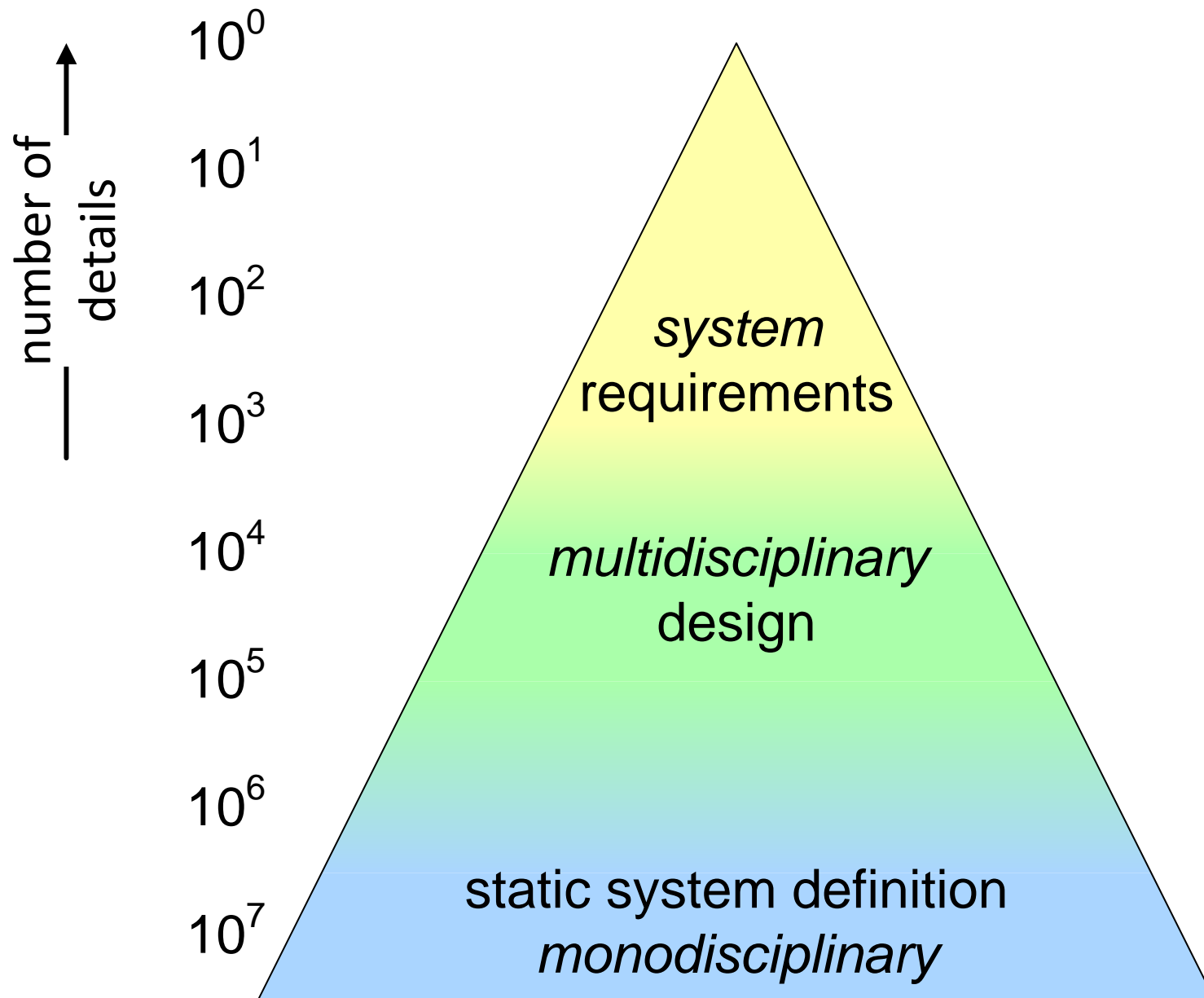


# From Engineering Disciplines to System Qualities

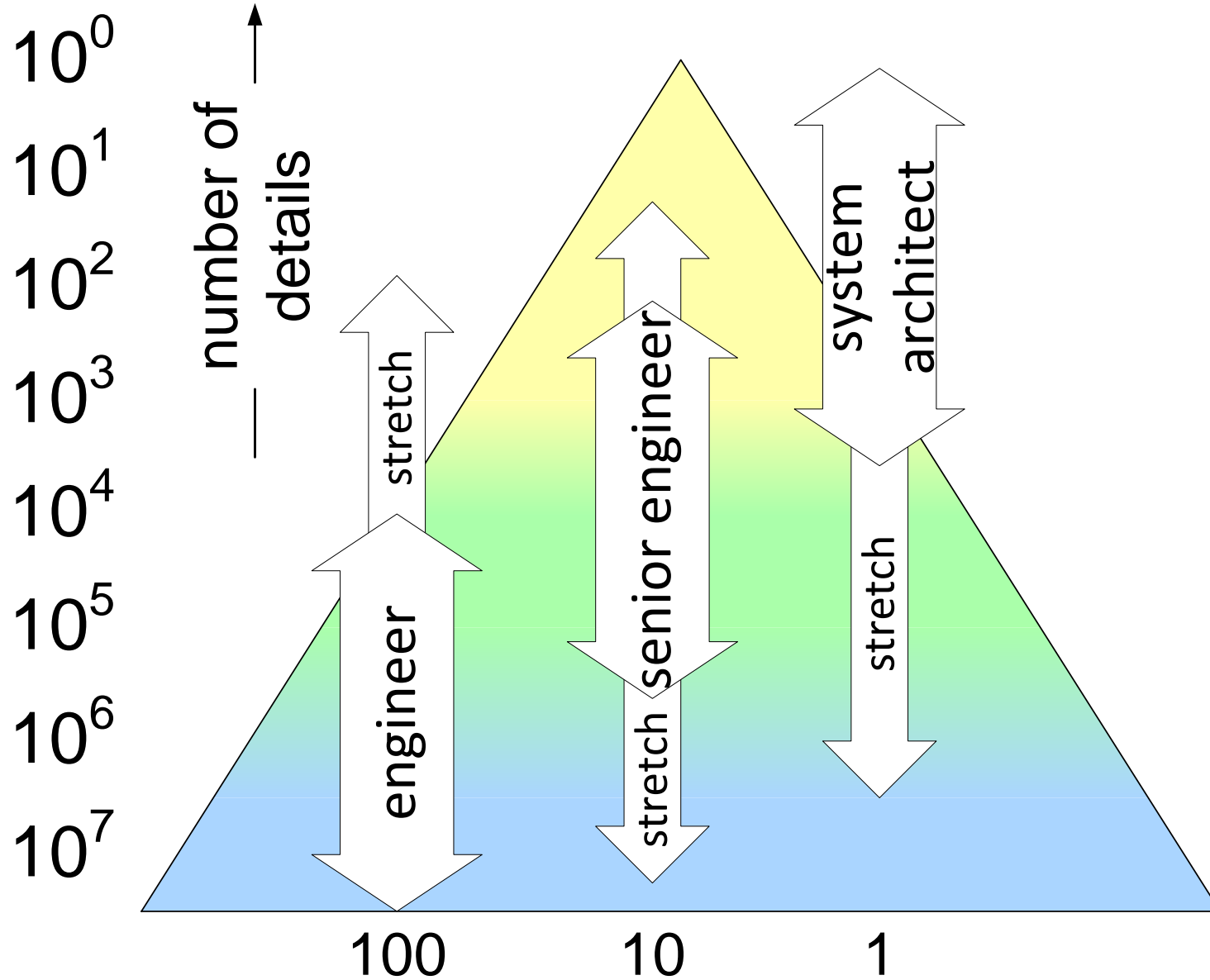
Systems Engineering: responsible for customer key drivers and key performance parameters of system



# Levels of Abstraction



# Lifting Engineers to System Concerns



Systems Engineering at Start-Up companies is applicable

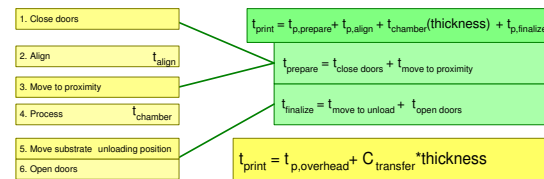
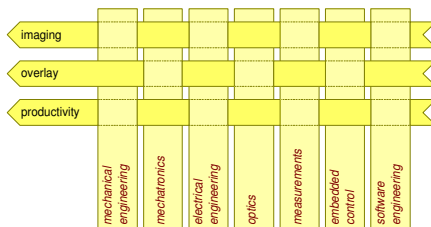
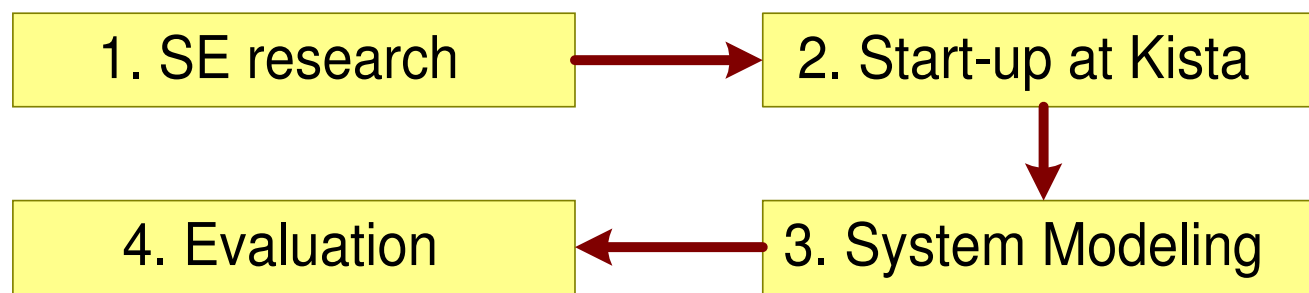
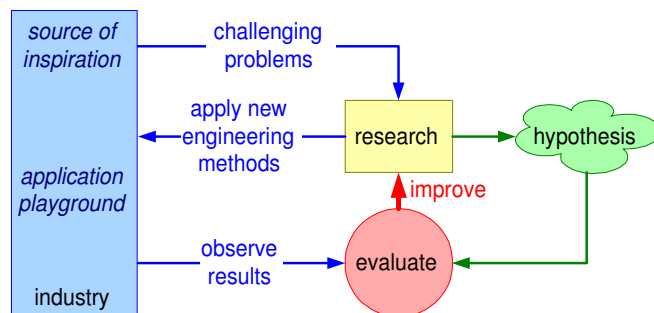
customization is required to adapt to:

- company size

- market and technology maturity

system models help to "lift" engineers to system level concerns

## Application of theory in practice



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is required for **learning and validation**